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AMENDMENTS TO THE CLAIMS:

The following list of claims will replace all prior versions, and listings, of claims. Please amend the claims as follows:

1.-40. (Canceled)

41. (Currently amended) A method for preparing a plasma polymerized surface on a substrate

comprising:

depositing a plasma polymer on the substrate using at least one organic compound monomer as a source to produce a plasma from which the plasma polymer is deposited; and

moving at least one of:

(i) the monomer source, and

(ii) the substrate,

relative to one another during plasma deposition such that at least part of the substrate has a plasma polymer deposit that is non-uniform,

wherein the substrate is separated from the monomer source by a mask plate having a at least one aperture that defines features of the deposited plasma polymer surface, the mask plate being spaced from the substrate.

42. (Original) The method of claim 41 wherein the substrate is moved relative to the monomer source.

43. (Original) The method of claim 41 wherein the monomer source is moved relative to the substrate.

44. (Previously presented) The method of claim 41 wherein the plasma polymer deposit is heterogeneous physically.

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45. (Previously presented) The method of claim 41 wherein the plasma comprises at least two

organic compound monomers.

46. (Previously presented) The method of claim 45 wherein the plasma polymer deposit is

heterogeneous chemically.

47. (Previously presented) The method of claim 41 wherein the organic compound monomer is

an alcohol.

48. (Previously presented) The method of claim 41 wherein the organic compound monomer is

an acid.

49. (Previously presented) The method of claim 41 wherein the organic compound monomer is

an amine.

50. (Previously presented) The method of claim 41 wherein the organic compound monomer is a

hydrocarbon.

51. (Previously presented) The method of claim 41 wherein the organic compound monomer is a

fluorocarbon.

52. (Previously presented) The method of claim 41 wherein the organic compound monomer is

tetraethyleneglycol monoallyl ether.

53. (Previously presented) The method of claim 41 wherein the organic compound monomer is a

siloxane.

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54. (Previously presented) The method of claim 41 wherein the organic compound monomer is

selected from the group consisting of allyl alcohol, acrylic acid, octa-1,7,-diene, allyl amine,

perfluorohexane, tetraethyleneglycol monoallyl ether or hexamethyldisiloxane (HMDSO).

55. (Previously presented) The method of claim 54 wherein the plasma polymer deposit is

produced from a single organic compound monomer.

56. (Currently amended) The method of claim 41 55 wherein the organic compound monomer

consists essentially of an ethylenically unsaturated organic compound.

57. (Previously presented) The method of claim 56 wherein the organic compound monomer

consists of tetraethyleneglycol monoallyl ether.

58. (Previously presented) The method of claim 56 wherein the organic compound monomer is

an alkene, a carboxylic acid, an alcohol or an amine.

59. (Currently amended) The method of claim 41 54 wherein the plasma polymer deposit

consists of a mixture of two or more ethylenically unsaturated organic compounds.

60. (Previously presented) The method of claim 59 wherein the organic compound monomer is

selected form the group consisting of an alkene, a carboxylic acid, an alcohol, or an amine.

61. (Currently amended) The method of claim 41 55 wherein the organic compound monomer

consists essentially of a saturated organic compound.

62. (Currently amended) The method of claim 41 55 wherein the organic compound monomer

consists essentially of an aromatic compound or a heterocyclic compound.

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63. (Previously presented) The method of claim 41 wherein the organic compound monomer is

polymerisable and has a vapor pressure of at least 6.6x10⁻² mbar at room temperature.

64. (Previously presented) The method of claim 44 wherein the plasma polymer deposit is a co-

polymer produced from at least two organic compound monomers.

65. (Previously presented) The method of claim 64 wherein the co-polymer comprises at least

one organic compound monomer that comprises at least one hydrocarbon.

66. (Previously presented) The method of claim 65 wherein at least one hydrocarbon is an

alkene.

67. (Previously presented) The method of claim 41 wherein the plasma polymer deposit is

deposited on said substrate in spatially separated dots.

68. (Previously presented) The method of claim 41 wherein the plasma polymer deposit is

deposited on said substrate in tracks or lines.

69. (Previously presented) The method of claim 41 wherein the chemical composition of the

plasma polymer deposit is heterogenous along its length.

70. (Previously presented) The method of claim 41 wherein the chemical composition of the

plasma polymer deposit is heterogenous in its height.

71. (Previously presented) The method of Claim 69 wherein the plasma polymer deposit is

deposited on said substrate in spatially separated dots.

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72. (Previously presented) The method of Claim 70 wherein the plasma polymer deposit is

deposited on said substrate in spatially separated dots.

73. (Previously presented) The method of Claim 69 wherein the plasma polymer deposit is

deposited on said substrate in tracks or lines.

74. (Previously presented) The method of Claim 70 wherein the plasma polymer deposit is

deposited on said substrate in tracks or lines.

75. (Previously presented) The method of claim 41 wherein the substrate is selected from the

group consisting of glass, plastics, nitrocellulose, nylon, metal, ceramics, quartz, metal films and

silicon wafer.

76. (Previously presented) The method of claim 75 wherein the substrate is a plastic selected

from the group consisting of polyethylene terephthalate, polyethylene, polyvinyl chloride,

polypropylene and polystyrene.